## 国際会議 2019 年度

• [05] 2019/10/25@Sendai in Japan

The 15th Symposium of Japanese Research Community on X-ray Imaging Optics

Development and application of hard X-ray spectro-ptychography

OM. Hirose, T. Higashino, N. Ishiguro, Y. Takahashi

 [04] 2019/10/16@Rochester in USA SPIE OPTIFAB (2019)

Measurement of a concave spherical mirror with 50 mm radius of curvature by three dimensional nanoprofiler using normal vector tracing

OY. Toyoshi, K. Hashimoto, J. Kang, K. Endo

• [03] 2019/09/24@Barcelona in Spain

World Congress on Laser, Optics and Photonics, (2019)

Freeform measurements with sub-nanometer precision by non-contact three-dimensional nanoprofiler based on normal vector tracing method

OJ. Kang and K. Endo

• [02] 2019/07/18@Changchun in China

Light Conference (2019)

Non-contact three-dimensional profiler with sub-nanometer precision using normal vector method

OJ. Kang and K. Endo

K. Endo

• [01] 2019/06/24@Munich in Germany

SPIE Optical Metrology (2019)

Absolute distance measurement of optical path length of non-contact three-dimensional nanoprofiler based on normal vector tracing method by tandem white-light interferometer OJ. Kang, T. Kitayama, R. Kizaki, Y. Toyoshi, K. Hashimoto, A. Winarno, K. Takamasu, K. Yamamura,